



Docket No.: 8733.154.00-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Jin Jang, et al.

Application No.: 09/350,313

Filed: July 9, 1999

For: METHOD OF CRYSTALLIZING
AMORPHOUS SILICON LAYER AND
CRYSTALLIZING APPARATUS THEREOF

Confirmation No.: 7883

Group Art Unit: 1765

Examiner: R. Kunemund

Customer No.: 30827

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AMENDMENT

MS Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Introductory Comments

In response to the Office Action dated June 23, 2003 (Paper No. 28), please amend the above-identified U.S. Patent application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks begin on page 10 of this paper.